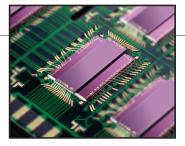
# data sheet



### Stacked CSP (SCSP):

The Stacked CSP (SCSP) family leverages Amkor's industry leading ChipArray® Ball Grid Array (CABGA) manufacturing capabilities. This broad high volume infrastructure enables the rapid deployment of advances in die stacking technology across multiple products and factories to achieve lowest total cost requirements.

Stacked CSP technology enables the stacking of a wide range of different semiconductor devices to deliver the high level of silicon integration and area efficiency required in portable multi-media products. Stacked CSP utilizes high density thin core substrates, advanced materials (ie: thin film die attach adhesive, fine filler epoxy mold compound), along with leading-edge wafer thinning, die attach, wire bonding and molding capabilities to stack multiple devices in a conventional fine pitch BGA (FBGA) surface mount component. These advanced assembly capabilities in combination with Amkor's expertise in design and test, enable stacks up to 16 active devices while optimizing yield and mounted height requirements. Many customers have relied on Amkor to solve their highest density and most complex device stack combinations. As a result, Amkor has established industry leadership in stacking pure memory, mixed signal, and logic + memory devices, including NAND, NOR and DRAM memory, digital base band or applications processors + high density flash or mobile DRAM devices. Designers are looking to Stacked CSP technologies to achieve a high level of integration, along with size and cost reductions in future chip set combinations.





# Stacked CSP

#### Features:

- 4-21 mm body size
- Package height down to 0.8 mm
- High die count pure memory stacks
- Design, assembly and test capabilities that enable stacking of DRAM with Logic or Flash memory devices
- Logic/Flash, Digital/Analog and other ASIC/Memory combinations of 320 I/O and greater
- Established package infrastructure with standard **CABGA** footprints
- · Consistent product performance, high yields and reliability
- JEDEC Standard Outlines including MO-192 and MO-219
- Thin DA film and spacer technology
- Extended die overhang wire bonding
- Low loop wire bonding less than 75 µm
- Vacuum transfer and compression molding
- Wafer thinning / handling to 40 µm
- Pb free, RoHS compliant and Green materials
- Passive component integration options

### Reliability:

Amkor assures a reliable performance by continuously monitoring key indices:

Package Level:

- Moisture Resistance Testing JEDEC Level 3 @260 °C
- Additional Test Data at [(30 °C/85%RH/96hrs)+260]x2or3
- Temp Cycle
- -55/+125 °C. 1000 cycles Unbiased Autoclave/PCT 121 °C/100% RH/2atm, 168 hours
- Temp/Humidity
- 85 °C/85%RH/1000 hours
- High Temp Storage
- 150 °C. 1000 hours

Board Level:

- Thermal Cycle
- -40/+125 °C, 1000 cycles

### **Applications:**

Portable multi-media devices includina cell phones, digital cameras, PDAs, gudio players and mobile gaming employ SCSP solutions to address a range of design requirements, including:

- Higher memory capacity and more efficient memory architectures
- Smaller, lighter and more innovative new product form factors
- Lower cost and more space efficient

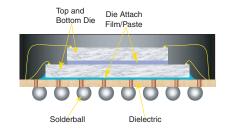


VISIT AMKOR TECHNOLOGY ONLINE FOR LOCATIONS AND TO VIEW THE MOST CURRENT PRODUCT INFORMATION.

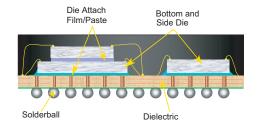
> DS573H Rev Date: 09'10

# data sheet

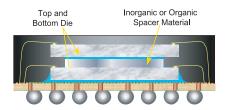
# **Stacked CSP Cross Section**2 Die on 2-Layer Laminate Structure



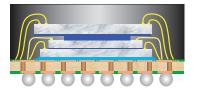
# **Stacked CSP Cross Section** 2+1 Die on 4-Layer Laminate Structure



### Same Size (SS) Die Stacked CSP Cross Section 2 Die on 2-Layer Laminate Structure



### Stacked CSP Cross Section 3+1 Logic + Memory



# Stacked CSP

## **Process Highlights**

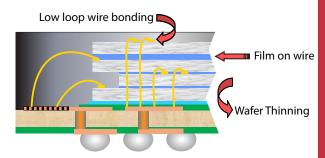
Die qty, stack Up to 5 high die configurations Ball pad pitch 0.4, 0.5, 0.65, 0.75, 0.8 mm Die thickness (min) down to 40  $\mu m$ 60, 100 or 150 μm Laminate core thickness 0.25, 0.30, 0.40, 0.46 mm Ball diameter 40 µm (In-line) Die bond pitch (min) with roadmap to 25 µm 5 mm (200 mils) Wirebond length (max) Wirebond dia (min) 18, 20, 25, 30 µm 200 & 300 mm wafers Wafer thinning

#### Standard Materials

Substrate

- Dielectric Laminate (e.g., E679, BT) Polyimide (e.g., Kapton®) - Layer count (Laminate) Device type Silicon, SiGe, etc. Film DA compatible with all passivation types Die attach High tensile strength Wire type, Gold Thixotropic Epoxy (Black) Encapsulant Solderball 63Sn/37Pb & PbFree Sn/3-4Ag/0.5Cu Marking Laser

# **Stacked CSP Key Technologies**



Contact Amkor for Daisy chain sample availability and the latest SCSP capabilities.

www.amkor.com